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N THE UNITED STATES PATENT & TRADEMARK OFFICE

PROJECTION SYSTEM AND METHOD FOR FABRICATING

AMENDMENT

Box: Non-Fee Amendment Assistant Commissioner for Patents Washington, DC 20231

Dear Sir:

In response to the office action mailed January 4, 2001, Applicant hereby submits the following amendment.

IN THE SPECIFICATION

On page 7, rewrite the paragraph beginning on line 21 as follows:

Figure 4 is a plot of the x-y distribution of dithered bilevel masking cells for an illumination aperture consisting of four circular normal distributed-intensity zones placed at diagonal positions corresponding to off-axis illumination for geometry oriented in horizontal and vertical directions. The axes are divided into relative distances using the center and the edges of the mask.

On page 7, rewrite the paragraph beginning on line 33 as follows:

Figure 7 is a plot of the x-y distribution of dithered, bilevel masking cells for an illumination aperture consisting of four elliptical normal distributed-intensity zones placed at diagonal positions corresponding to off-axis illumination for geometry oriented in horizontal and vertical directions. The axes are divided into relative distances using the center and the edges of the mask.

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